Organic Secondary Ion Mass Spectrometry: Signal Enhancement by Water Vapor Injection

Taoufiq Mouhib, Arnaud Delcorte, Claude Poleunis, and Patrick Bertrand

Institute of Condensed Matter and Nanosciences–Bio and Soft Matter (IMCN/BSMA), Université catholique de Louvain, Louvain-la-Neuve, Belgium

The enhancement of the static secondary ion mass spectrometry (SIMS) signals resulting from the injection, closely to the sample surface, of H₂O vapor at relatively high-pressure, was investigated for a set of organic materials. While the ion signals are generally improved with increasing H₂O pressure upon 12 keV Ga⁺ bombardment, a specific enhancement of the protonated ion intensity is clearly demonstrated in each case. For instance, the presence of H₂O vapor induces an enhancement by one order of magnitude of the [M + H]⁺ static SIMS intensity for the antioxidant Irgafos 168 and a ~1.5-fold increase for polymers such as poly(vinyl pyrrolidone). (J Am Soc Mass Spectrom 2010, 21, 2005–2010) © 2010 American Society for Mass Spectrometry

In the last two decades, static SIMS has become one of the most useful techniques for organic, polymeric, and biochemical materials characterization [1–5]. In conjunction with instrumental developments, specific sample preparation procedures have been proposed to improve the molecular signal intensities for organic materials. The utilization of matrices, such as those used in matrix-assisted laser desorption/ionization (MALDI), was found to improve sensitivity very significantly by increasing the intensity of the protonated molecular ions [6, 7]. Another protocol, using metal condensation over the organic surface, was called metal assisted-SIMS (MetA-SIMS). It was found to enhance the yields of characteristic ions by one or two orders of magnitude depending on the sample, and even more in some instances [8–10]. With the advent of polyatomic projectiles, such as SF₅⁺, C₆₀⁺, Bi_n⁺, and Au_n⁺, huge molecular ion yield enhancements have been measured (up to 1000-fold increases in signal compared with Ga⁺ atomic projectiles), leading to a revolution of the field of organic SIMS characterization [11–15]. With the additional molecular depth profiling capabilities of SF₅⁺ and C₆₀⁺ cluster beams, one can now hope to relate the performance characteristics of organic devices to their surface molecular composition in a much more quantitative way. Nevertheless, in spite of these multiple improvements, useful molecular signals remain low for the next generation of organic SIMS applications, involving nanometer-scale 3D molecular characterization of surfaces. Indeed, if some current cluster beams can be focused to a diameter of 100 nm or less, the corresponding reduction of the interrogated volume raises again

the level of sensitivity needed for analysis. Therefore, what the field needs today is a method that can be associated to cluster beam bombardment to provide an additional level of molecular signal enhancement.

Since the emergence of SIMS, it has been shown that the ionization probability depends highly on the chemical environment [16]. This effect is routinely used in SIMS depth profiling by applying oxygen sputtering to increase positive ion yields and cesium sputtering to increase negative ion yields [17, 18]. In those cases, the secondary ion yields strongly increase with the concentration of the reactive species. Ions can also be formed by the recombination of a sputtered neutral atom M or cluster with an emitted Cs⁺ ion giving a MCs⁺ secondary ion, an effect that is used for quantitative depth profiling [19]. It has also been recognized in inorganic SIMS that the secondary ion yield is high for elements that form a strong ionic bond with oxygen [20], fluorine [21], or chlorine [22]. Following this idea, different gas flooding techniques have been proposed. For instance, Gao et al. [22] and Sielanko et al. [23] found significant secondary ion yield enhancements for many elements, using CCl₄ gas flooding combined with oxygen ion bombardment and CF₂Cl₂ gas flooding under cesium ion bombardment, respectively. In addition, it is known from the focused ion beam (FIB) milling of organic materials that H₂O injection at high-pressure increases the sputter rates by a factor of 10 and more [24]. Even the sputtering of diamond is enhanced by H₂O injection. Finally, the water ice present upon sample freezing of biological materials for SIMS analysis is also believed to be an efficient source of protons for cationization [25–27]. Therefore, flooding the analyzed surface with H₂O gas appears to be a promising approach to enhance the molecular ion yields in organic SIMS.

Address reprint requests to Dr. T. Mouhib, Institute of Condensed Matter and Nanosciences–Bio and Soft Matter (IMCN/BSMA), Université catholique de Louvain, Croix du Sud, 1 bte 3; Bât. Boltzmann (a1), B-1348 Louvain-la-Neuve, Belgium. E-mail: taoufiq.mouhib@uclouvain.be.

In this article, we report on H₂O vapor flooding experiments that lead to a significant enhancement of the positive SIMS intensities of a set of organic materials. This new protocol, tested with a 12 keV Ga⁺ primary beam, is easily transferable to other bombardment conditions. The role of the H₂O pressure in the specific intensity enhancement of protonated ions emitted from a polymer antioxidant and from high-molecular-weight polymers was examined in detail.

Experimental

Samples

Various organic molecules, including antioxidant *Tris* (2,4-di-*tert*-butylphenyl) phosphite (Irgafos 168) and four polymers (poly(vinyl pyrrolidone), PVP; poly(4-vinyl pyridine), P4VP; poly(methyl methacrylate), PMMA; and polystyrene, PS) were dissolved to a concentration of 10 mg/mL in the appropriate solvent (Table 1) and spin-cast (10,000 rpm⁻¹; 4000 rpm; 60 s) on a clean 1 cm × 1 cm silicon wafer. Thickness measurements of the organic films were made using a spectroscopic ellipsometer UVISSEL M200, HORIBA Jobin-Yvon (Longjumeau Cedex, France). Resulting organic film thicknesses are shown in Table 1.

TOF-SIMS Instrument

The secondary ion mass analyses were performed in a Phi-EVANS (Chanhassen, MN, USA) time-of-flight SIMS (TRIFT 1) using a 15 keV Ga⁺ beam (~1 nA DC current; 22 ns pulse width bunched down to 1 ns; 5 kHz repetition rate) with the sample voltage at 3 kV [28]. To improve the measured intensities, the secondary ions were post-accelerated by a high voltage (7 kV) in front of the microchannel plate detector. TOF-SIMS spectra in the mass range $0 < m/z < 1000$ were obtained by collecting the secondary ion signals from 180 s acquisitions on a 120 × 120 μm² sample area. The total ion fluence accumulated during an acquisition cycle was 8.1×10^{11} ions/cm², which ensured the static bombardment conditions. For reproducibility the SIMS measurements were made on three different samples (three measurements on each).

Gas Injection System

A modification was made in the sample chamber to introduce water vapor closely to the sample surface

using a gas injection system, illustrated schematically in Figure 1. The gas injection system and the differential pumping are adapted to reach sufficiently high pressures at the sample surface while the pressure of the chamber remains low. The H₂O vapor was fed to the sample surface through a 0.5-mm-diameter injector needle positioned to within 1 mm of the sample. To prevent the close proximity of the nozzle to the surface from adversely affecting the secondary ion extraction field and degrading the collection efficiency, the nozzle was electrically grounded. The gas flow from the reservoir was controlled using a needle valve and the gas pressure at the entrance of the injector needle was monitored using a variable leak Granville-Phillips valve (Boulder, CO, USA). The pressure measured at the entrance of the injector was about 1×10^{-3} Torr. The real partial pressure at the sample surface during the water vapor flooding might be different from the measured pressure in the chamber, because of the gauge location in the instrument. But at the equilibrium, the measured chamber pressures should be proportional to the pressures at the sample surface, with the ratio remaining constant during the pressure variation. The pressure at the sample should be close to the measured entrance pressure, while the pressure of the chamber remains below $\approx 5 \times 10^{-5}$ Torr.

Results and Discussion

The goal of this article is to assess the interest of the injection of high-pressure water vapor in the selvage region of organic samples for SIMS analysis. The choice of the used set samples is motivated by the wish to test the ability of the proposed water vapor protocol to enhance SIMS intensities for both low and high molecular weight organic materials. The discussion is divided in two sections. The first section investigates the case of the quasi-molecular ions of a low molecular weight polymer additive. The second section addresses the effect of the H₂O gas on the enhancement of the fingerprint ions of high molecular weight polymers. It should be mentioned here that for clean aluminum and silicon substrates, we did not measure any effect of the H₂O pressure on the characteristic secondary ion yields.

Polymer Additive

The polymer additive analyzed in the context of this study is the antioxidant Irgafos 168. The absolute intensity of the

Table 1. Description of the samples

Molecule	Acronym	M _w (Da)	Source	Solvent	Thickness (nm)
Irgafos 168 <i>Tris</i> (2,4-di- <i>tert</i> -butylphenyl) phosphite	Irgafos 168	647	Ciba Specialty Chemicals Inc.	Toluene	103.5 ± 2.4
poly(vinyl pyrrolidone)	PVP	29000	Sigma-Aldrich	Ethanol	106.7 ± 4.3
poly(4-vinyl pyridine)	P4VP	60000	Sigma-Aldrich	Ethanol	105.8 ± 1.8
poly(methyl methacrylate)	PMMA	30000	Sigma-Aldrich	Acetone	88.7 ± 1.2
Polystyrene	PS	30000	Sigma-Aldrich	Toluene	92.4 ± 1.6

Figure 1. Schematic illustration of the gas injection system.

protonated molecule $[M + H]^+$ ($C_{42}H_{64}O_3P^+$), is shown in Figure 2a as a function of the chamber pressure (which should be proportional to the partial pressure of the H_2O vapor at the surface sample). The increase of the water vapor pressure induces the increase of the protonated molecule signal until a maximum is reached, at $\sim 10^{-6}$ Torr. At higher pressure, the intensity decreases steeply, which is probably due to the reduction of the mean free path of the emitted ions caused by their interaction with the gas. The absolute $[M + H]^+$ intensity recorded with decreasing water pressure is also shown. The curves obtained upon raising or decreasing pressure are quite similar, which means that the signal variation is reversible. The reproducibility is reasonably good, even though slight differences are observed in (1) the precise value of the maximum intensity and (2) the measured pressure at the maximum (3.9×10^{-6} Torr in the case of increasing pressure and 1.4×10^{-6} Torr in the case of decreasing pressure). Those differences can be tentatively explained by two effects. First, the pressure gauge is located at some distance from the surface and, therefore, it does not necessarily provide an instant reflection of the local pressure around the impact point. Second, possibly, after the first experiment conducted with increasing pressure, H_2O molecules remain adsorbed on the sample surface, thereby increasing the probability of chemical reaction in the impact region.

The observed H_2O pressure-dependent enhancement of the molecular ion intensities might be explained by an increase of the sputtering yield, as was observed upon FIB milling of organic materials in presence of H_2O gas, or by specific ionization effects. To obtain some information about the ionization itself, Figure 2b shows the pressure dependence of the relative intensities of molecular, protonated, and deprotonated ions emitted from Irgafos 168 in the same conditions. The maximum intensity of the $[M + H]^+$ secondary ion is ~ 30 times larger than the intensity measured for

normal vacuum conditions (without gas flooding). In comparison, the intensity enhancements of $[M]^+$ and $[M - H]^+$ are, respectively, 1.7 and 2 times lower than that of $[M + H]^+$. This result demonstrates that there is a differential effect of the H_2O flooding on the intensity of ions that are formed by different ionization mechanisms. It also confirms that the presence of H_2O favors particularly the formation of protonated molecular ions.

High Molecular Weight Polymers

All the polymeric materials examined in this study (PVP, P4VP, PMMA, and PS) exhibit quite similar intensity variations of the protonated repeat unit ion $[M + H]^+$ in the presence of H_2O vapor. The measured enhancement factors are summarized in Table 2. In comparison with the low molecular weight polymer additive, Irgafos 168, they are significantly smaller (~ 1.5). This is probably due to the specific chemistry of the Irgafos 168. In fact, in the presence of water, such an active phosphite undergoes hydrolysis and produce H_3PO_3 molecules, which can act as an additional source of protons [29].

The case of PVP provides a good illustration of the common behavior observed for all the considered polymers. With the same normalization procedure as Figure 2b, Figure 3 presents the relative intensities of the $[M - H]^+$, $[M]^+$ and $[M + H]^+$ ions of PVP as a function of the H_2O vapor pressure, under 12 keV Ga^+ bombardment. The results also show that H_2O vapor flooding induces a preferential increase of the protonated ion intensity. Therefore, all our results point to a significant influence of the injected H_2O gas on the protonation reactions occurring in the selvedge of the analyzed materials.

Protonation Mechanism

To investigate the origin of the protons leading to higher yields of $[M + H]^+$ ions, TOF-SIMS spectra have

Figure 2. Effect of H₂O vapor injection for Irgafos 168. (a) Variation of the absolute intensity of the protonated ion [M + H]⁺ for increasing water pressure (open squares) and for decreasing water pressure (filled circles). The bottom-left inset shows the chemical formula of Irgafos 168. (b) Relative intensities of the molecular (open square), protonated (filled circle) and deprotonated (filled triangle) ions.

been collected in the presence of D₂O vapor. The absolute intensity of the deuterated molecule [M + D]⁺ as a function of the chamber pressure is shown in

Table 2. Maximum enhancement factors of the protonated repeat unit [M + H]⁺ of the polymers due to the H₂O vapor exposure

Polymer	Enhancement factor
PVP	1.6 ± 0.1
P4VP	1.6 ± 0.1
PMMA	1.4 ± 0.1
PS	1.1 ± 0.1

Figure 3. Chamber pressure dependence of the relative [M]⁺, [M – H]⁺, and [M + H]⁺ ion intensities of PVP upon H₂O flooding (12 keV Ga⁺ bombardment). The measured values are normalized to those obtained under Ga⁺ bombardment without flooding. The bottom-left inset shows the chemical formula of PVP.

Figure 4 for an Irgafos sample. In the same way that it appeared for the water vapor injection, the increase of the D₂O vapor pressure induces the increase of the deuterated molecule signal until a maximum is reached, at ~10^{–6} Torr. Due to the low abundance of free deuterium ions in toluene, which was used as solvent for the Irgafos, the formation of the deuterated molecule

Figure 4. Chamber pressure dependence of the absolute intensity of deuterated ion [M + D]⁺ upon D₂O flooding (12 keV Ga⁺ bombardment) for the Irgafos 168.

ion must be caused upon ionization in the presence of D₂O vapor. The enhancement of [M + D]⁺ peak is clear evidence supporting the transfer of deuterium from D₂O in the region surrounding the departing molecules. Because the local pressure is relatively high, D₂O is probably adsorbed onto the surface, and may act as a matrix or produce an additional source of deuterons by chemical interaction. On the other hand, deuteron exchanges occurring between the desorbed fragments and the D₂O vapor molecules in the gas phase cannot be excluded. It should be mentioned that [M + H]⁺ and [M + 3]⁺ ions are also detected, indicating an H/D exchange, which could be due to the formation of fragments in the sputtering zone. Nevertheless, their corresponding enhancements are negligible compared with the observed enhancement for [M + D]⁺.

Conclusion

In this article, we have demonstrated a simple but efficient method to improve the analytical performance in organic SIMS, using water vapor injection near the sample surface. A significant enhancement of the positive secondary ion intensities was observed for organic materials irradiated with Ga⁺ ions in the presence of H₂O gas. In addition, our results show that the enhancement depends on the type of secondary ion and that the formation of protonated ions is specifically favored. For the low molecular weight additive Irgafos 168, the normalized [M + H]⁺ intensity increased by one order of magnitude upon H₂O flooding. The enhancement factors are lower with high molecular weight polymers. Nevertheless, the intensity of the protonated monomer ions is also enhanced preferentially in comparison with those of the deprotonated and the bare monomer ions. TOF-SIMS analyses of Irgafos 168 upon D₂O flooding (or H₂O flooding) demonstrate that the enhancement of the deuterated (or protonated) ion intensity is caused by deuteron (or proton) transfer from the water molecules. Advantages of this method are that it can be easily used whatever the kind of the organic sample and it can be set up independently of the operating ion source. Our current set up still needs optimization, for instance in terms of differential pumping, pressure measurement, or nature of the reacting gas. Therefore, we hope to reach higher ion yield enhancements. Finally, we also plan to check whether the signal enhancements measured upon Ga⁺ ion bombardment also occur with cluster primary ions, such as C₆₀⁺.

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